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(54) **METHODS AND ELECTROLYTES FOR
ELECTRODEPOSITION OF SMOOTH FILMS**

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This patent is subject to a terminal dis-
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See application file for complete search history.

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(57) **ABSTRACT**

Electrodeposition involving an electrolyte having a surface-
smoothing additive can result in self-healing, instead of self-
amplification, of initial protuberant tips that give rise to
roughness and/or dendrite formation on the substrate and/or
film surface. For electrodeposition of a first conductive mate-
rial (C1) on a substrate from one or more reactants in an
electrolyte solution, the electrolyte solution is characterized
by a surface-smoothing additive containing cations of a sec-
ond conductive material (C2), wherein cations of C2 have an
effective electrochemical reduction potential in the solution
lower than that of the reactants.

19 Claims, 5 Drawing Sheets

